

Docket No. 50751

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANT: T. Zampini et al.

FILED: HEREWITH

FOR: NOVEL POLYMERS AND PHOTORESIST COMPOSITIONS  
FOR SHORT WAVELENGTH IMAGINGTHE HONORABLE COMMISSIONER OF PATENTS AND TRADEMARKS  
WASHINGTON, DC 20231

SIR:

## PRELIMINARY AMENDMENT

Applicant files herewith the above-identified application. Please amend the application as follows before calculating the filing fee of the application.

## IN THE CLAIMS

Please renumber claims 16-34 as appearing on page 24, line 11 through page 26, line 21 as claims 18-36 respectively. The claim amendments below reflect that claim renumbering.

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| 6. | (amended) | The method of claim 1 wherein the resin comprises phenolic units.   |
| 7. | (amended) | The method of claim 1 wherein the polyol is an aromatic compound.   |
| 8. | (amended) | The method claim 1 wherein the polyol is a bisphenol, a polyhydroxybenzene or a polycarboxylic acid compound.   |
| 9. | (amended) | The method of claim 1 wherein the methylene compound or keto compound is a benzyl compound, or an aldehyde substituted with one or more electronegative groups. |

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